Illumination and annealing characteristics of two-dimensional electron gas systems in metal-organic vapor-phase epitaxy grown Al$_x$Ga$_{1-x}$N/AlN/GaN heterostructures

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We studied the persistent photoconductivity (PPC) effect in Al$_x$Ga$_{1-x}$N/AlN/GaN heterostructures with two different Al compositions (x=0.15 and x=0.25). The two-dimensional electron gas formed at the AlN/GaN heterointerface was characterized by Shubnikov-de Haas and Hall measurements. Using optical illumination, we were able to increase the carrier density of the Al$_{0.15}$Ga$_{0.85}$N/AlN/GaN sample from 1.6 $\times$ 10$^{12}$ to 5.9 $\times$ 10$^{12}$ cm$^{-2}$, while the electron mobility was enhanced from 9540 to 21 400 cm$^2$/V s at $T=1.6$ K. The persistent photocurrent in both samples exhibited a strong dependence on illumination wavelength, being highest close to the band gap and decreasing at longer wavelengths. The PPC effect became fairly weak for illumination wavelengths longer than $\sim$530 nm and showed a more complex response with an initial negative photoconductivity in the infrared region of the spectrum ($\lambda>700$ nm). The maximum PPC efficiency for 390 nm illumination was 0.011\% and 0.005\% for Al$_{0.25}$Ga$_{0.75}$N/AlN/GaN and Al$_{0.15}$Ga$_{0.85}$N/AlN/GaN samples, respectively. After illumination, the carrier density could be reduced by annealing the sample. Annealing characteristics of the PPC effect were studied in the 20–280 K temperature range. We found that annealing at 280 K was not sufficient for full recovery of the carrier density. In fact, the PPC effect occurs in these samples even at room temperature. Comparing the measurement results of two samples, the Al$_{0.25}$Ga$_{0.75}$N/AlN/GaN sample had a larger response to illumination and displayed a smaller recovery with thermal annealing. This result suggests that the energy scales of the defect configuration-coordinate diagrams for these samples are different, depending on their Al composition. © 2006 American Institute of Physics.

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I. INTRODUCTION

Because of their potential applications in high-temperature, high-power, and high-frequency microwave electronics, Al$_x$Ga$_{1-x}$N/GaN heterostructures are attracting escalating research interest.\textsuperscript{1–5} Promising device performances have been reported as well as continuously improving transport properties. Better quality substrates, improved carrier transport properties. Understanding and minimizing defects are essential for further progress. The electronic defect state of the Al$_x$Ga$_{1-x}$N/GaN heterostructures can be altered by illumination of the sample at low temperatures. Associated with the change in defect configuration is the persistent photoconductivity (PPC) effect. Typically this effect leads to conductivity enhancement under optical illumination, which persists for a long period of time after the termination of optical excitation. PPC may have an adverse effect on stable device operation; however, it also provides a powerful tool to study the effect of carrier density on the transport properties.

PPC has been observed in most III-V semiconductor alloys including the Al$_x$Ga$_{1-x}$As material system, in which the effect was attributed to the excitation of the donor-vacancy (DX) centers.\textsuperscript{11–13} The PPC effect observed in GaN and Al$_x$Ga$_{1-x}$N epilayers was similarly attributed to defect complexes such as gallium vacancies, nitrogen antisites, deep-level impurities, and interacting defect complexes.\textsuperscript{14–23} For Al$_x$Ga$_{1-x}$N/GaN heterostructures, several groups have reported PPC experiments.\textsuperscript{24–26} The persistent increase in carrier concentration was explained by the transfer of photoexcited electrons from deep-level impurities in Al$_x$Ga$_{1-x}$N layers.\textsuperscript{24} However, the spectral illumination dependence of PPC in Al$_x$Ga$_{1-x}$N/GaN heterostructures has not been investigated. In addition, a systematic study of the thermal annealing effect, which returns the sample back to its original low-carrier-density state, would be of significant interest. Our motivation in this work is to explore the spectral illumination and thermal annealing characteristics of the PPC effect in Al$_x$Ga$_{1-x}$N/AlN/GaN heterostructures. We present our experimental results on the influence of PPC in high-mobility Al$_x$Ga$_{1-x}$N/AlN/GaN heterostructures grown by metal-organic vapor-phase epitaxy (MOVPE). Using the PPC effect, we extracted the relation between the carrier density and mobility for the heterostructures under investigation. The
spectral illumination and thermal annealing characteristics of the PPC effect and its variation with Al composition were also studied systematically.

II. EXPERIMENTAL DETAILS

The Al$_{1-x}$Ga$_{x}$N/AlN/GaN heterostructures were grown by custom low-pressure metal-organic vapor-phase epitaxy (LP-MOVPE) in a rotating-disk vertical MOVPE chamber. Ammonia (NH$_3$), trimethylgallium (TMGa), and trimethylaluminum (TMAI) were used as precursors for nitrogen, gallium, and aluminum, respectively. Hydrogen was used as the carrier gas and growth was accomplished under high-speed rotation (~500 rpm). The samples were grown on c-plane (0001) sapphire substrates. The epitaxial layer structure of the samples consisted of a thick (~3 μm) GaN layer, followed by a ~1 nm thick AlN interfacial layer, a ~25 nm Al$_{1-x}$Ga$_{x}$N layer, and a ~3 nm GaN cap layer, all nominally undoped. We used an AlN interfacial layer to reduce the alloy disorder scattering by minimizing the wave function penetration from the two-dimensional electron gas (2DEG) channel into the Al$_{1-x}$Ga$_{x}$N layer. To study the effect of Al composition in the Al$_{1-x}$Ga$_{x}$N layer, two samples were grown with $x$=0.25 (sample I) and $x$=0.15 (sample II). The growth was initiated with a 25 nm thick low-temperature (~550 °C) GaN nucleation layer. The 3 μm thick GaN epilayer was grown at 1010 °C under 200 mTorr and using a V/III ratio of ~4000. The chamber pressure and ammonia flow rate were decreased to 30 mTorr and 2 liter/min respectively, for the growth of AlN/Al$_{1-x}$Ga$_{x}$N layers. The growth temperature for these layers and the GaN cap layer was ~1060 °C.

Standard photolithography and reactive ion etching were used to define 600 μm long and 100 μm wide Hall-bar structures. Ohmic contacts were formed using Ti/Al/Ti/Au (30/100/30/50 nm) alloyed at 900 °C for 1 min.

III. RESULTS AND DISCUSSION

A. Magnetotransport measurements

To confirm the presence of a 2DEG and to extract the carrier density and mobility of the samples, magnetotransport measurements were performed using a variable temperature liquid-He cryostat equipped with a superconducting magnet. Shubnikov–de Haas (SdH) and Hall measurements were carried out at $T$=1.6 K within a magnetic field range of 0–6.6 T. Figure 1(a) shows the longitudinal resistivity ($\rho_{xx}$) and transverse (Hall) resistivity ($\rho_{xy}$) data measured at 1.6 K for sample I. Well-resolved magnetoresistance oscillations commencing around 2 T were observed, confirming the existence of a high-quality 2DEG. Quantum Hall steps in the Hall-resistivity curve accompany the SdH oscillations. The SdH oscillations without any beat characteristics indicated that only a single subband was occupied. Using $\rho_{xx}$ and $\rho_{xy}$, the 2DEG carrier density and mobility were determined to be $n$=3.0×10$^{12}$ cm$^{-2}$ and $\mu$=11 710 cm$^2$/V s at 1.6 K, respectively. Magnetotransport measurements of sample II revealed a lower carrier density and a lower mobility: $n$=1.6×10$^{12}$ cm$^{-2}$ and $\mu$=9540 cm$^2$/V s at 1.6 K. The SdH data of both samples are compared in Fig. 1(b). Sample II exhibited lower carrier density and higher sample resistance, which is a result of lower Al composition in the Al$_{1-x}$Ga$_{x}$N layer.

To increase the carrier density, samples were illuminated through the optical access window of the magnetocryostat for short periods with a flashlight and $\rho_{xx}$ monitored. After each illumination SdH and Hall measurements were performed with the sample kept in the dark. Typical SdH traces from sample I are shown in Fig. 2(a). Under illumination, a significant increase in carrier density was observed: from $n$=3.0×10$^{12}$ cm$^{-2}$ before illumination to $n$=6.7×10$^{12}$ cm$^{-2}$ after the illumination had saturated the sample. The PPC effect in sample II was even more pronounced: carrier density changed from 1.6×10$^{12}$ to 5.9×10$^{12}$cm$^{-2}$ under illumination. The corresponding electron mobility values were extracted from SdH and Hall data, which are plotted in Fig. 2(b). As can be seen from this data, the mobility increases with increasing carrier density for both samples. At low carrier densities the dominant scattering is due to charged impurities and the scattering rate from charged impurities decreases with increasing Fermi wave vector. Furthermore, there is an enhanced screening with increasing carrier density. The mobility-carrier density dependence observed in our samples is in agreement with the previous reports in AlGaAs/GaAs and AlGaN/GaN 2DEG structures. The enhancement in mobility with increasing carrier density is less significant at carrier densities higher than 4×10$^{12}$ cm$^{-2}$. Further increase in carrier density resulted in a saturation-like behavior near the end data points where maximum mobilities of 17 830 and 21 400 cm$^2$/V s were recorded for samples I and II, respectively. No decrease in mobility was observed within the carrier density range of the experiment. We should note that in previous measurements...
performed in a wider carrier density range, it is found that
the mobility first increased with carrier density, reached
a maximum, and then started to decrease. The mobility re-
duction at higher carrier densities was mainly attributed
to alloy disorder scattering and to interface roughness
scattering at even higher densities. Our nonde-
creasing high-mobility results confirm the effectiveness
of the thin AlN interfacial layer: not only did it enhance
the confinement of the 2DEG in the GaN channel, but it sup-
pressed the alloy disorder scattering significantly as well.
If we were able to increase the carrier density beyond
10^{12} cm^{-2}, we would observe the drop in mobility
due to interface roughness scattering and other scattering
mechanisms effective in the high carrier concentration regime.

B. Persistent photoconductivity measurements

The magnetotransport measurements demonstrated
the presence of the PPC effect in our Al_{x}Ga_{1-x}N/AlN/GaN
samples. With the intention of investigating this PPC effect,
we conducted spectral illumination and annealing
experiments. Before illumination, in dark and at low tem-
perature, the sample was in an equilibrium state with low
carrier density and high sample resistance. With illumination,
the sample state was changed to a nonequilibrium state,
where the carrier density is higher and sample resistance
is lower. The sample was then returned back to its original (or
close to original) stable state by thermal annealing at suffi-
ciently high temperatures. The illustration in Fig. 3(a) shows
the cycle used for the PPC experiments.

The conductivity evolution under the influence of illumina-
tion and annealing can be successfully described by defect
configuration diagrams. Extensive PPC studies in the
AlGaAs/GaAs system have been performed within this
framework. Our purpose is to study and analyze the PPC
effect in AlGaN/AlN/GaN heterostructures within the same
framework with the goal of finding the threshold optical ex-
citation energy for PPC as well as the critical annealing tem-
perature needed for total recovery. Figure 3(b) shows a rep-
resentative configuration coordinate diagram for a deep-level defect
responsible for the PPC effect. Process 1 describes the optical excita-
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than the threshold energy, E_t. The reverse process of anneal-
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level, and is shown as process 2, where the critical thermal
barrier to electron capture is E_c. It is possible that there
might be a wide range of defects with different energy scales
that participate in the PPC effect. To understand the energy
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cident optical power was monitored using a calibrated UV-enhanced Si detector (power meter). The sample excitation current was kept low at 1 μA to prevent heating. The longitudinal sample voltage and Hall voltage were measured using a low-noise preamplifier and lock-in amplifier. From these data, longitudinal resistivity ($\rho_{xx}$) and Hall resistivity ($\rho_{xy}$) values were determined. The samples were illuminated for 20 min at six different sub-band gap wavelengths: 380, 420, 490, 530, 720, and 870 nm. All measurements were done at $T=4.5$ K. To block the possible higher harmonics, long-pass optical filters were utilized before the monochromator. Samples were annealed above room temperature after each illumination sequence to recover the equilibrium state.

In order to analyze the temporal PPC data, we have converted the resistivity curves into corresponding carrier density curves using the mobility versus carrier concentration data obtained during magnetotransport measurements. Note that, in the context of the PPC effect, the carrier density is a more physically meaningful parameter than resistivity, as the change in carrier density is directly related to the number of defects that have changed by optical illumination. Figure 5 shows the typical change of carrier density with illumination at 420, 490, and 530 nm for both samples. Both samples exhibit an initial fast increase followed by a slower but steady enhancement. The rate of carrier density enhancement depends strongly on the illumination wavelength. The rate of change in carrier density was over an order of magnitude when the illumination wavelength was changed from 420 to 530 nm. Figure 5 inset presents the corresponding temporal change of resistivity of sample I under 420 nm illumination. Both samples showed decreasing PPC response as the illumination wavelength was increased. The PPC effect becomes very small at wavelengths longer than 530 nm.

To compare the PPC response curves at different wavelengths correctly, we need to normalize the rate of conductivity change with the incident photon flux. Therefore, we defined a dimensionless parameter, PPC efficiency ($\eta$), as follows: the rate of electrons excited and contributing to the persistent photocurrent divided by the incident photon flux, $\eta = \frac{dn/dt}{I_o/h\nu}$, where $dn/dt$ was obtained by differentiating the temporal carrier density curves in Fig. 5, $I_o$ is the optical intensity incident on the sample surface, and $h\nu$ corresponds to the energy of a single incident photon. We should note that this efficiency parameter unlike the "quantum efficiency" used for characterization of photodiodes or light emitting diodes is a quantity which is expected or desired to be lower for better device performance.

After taking the surface reflections into account, PPC-efficiency values were calculated and plotted as a function of photon energy (Fig. 6). As the illumination energy was changed from 3.2 to 2.3 eV, the corresponding PPC efficiency decreased exponentially with a similar rate for both samples. However, at 1.7 eV (720 nm) and 1.4 eV (870 nm) this trend was interrupted. A more complex PPC response
was observed at these infrared wavelengths. An initial decrease in carrier density was noticed immediately after illumination started. Shortly after this negative photoconductivity response the carrier density started to increase slowly, indicating a positive PPC. The overall PPC response after 20 min was positive. At this point we are not sure about the origin of the initial negative photoconductive response under infrared illumination.

The maximum PPC-efficiency values achieved for samples I and II were 0.011% and 0.005%, respectively. This means that 10 000 incident 3.2 eV photons were able to excite at most one electron which contributed to the 2DEG channel persistently. Although this efficiency seems to be low, within 20 min, it changed the carrier density of sample I from $3.0 \times 10^{12}$ to $5.0 \times 10^{12}$ cm$^{-2}$. The inset of Fig. 6 shows the PPC-efficiency curve of sample I in linear scale, where the significant drop is seen easily. For photon energies smaller than 2.3 eV, the pronounced PPC effect becomes very weak. We estimate $E_c = 2.0 \pm 0.2$ eV as the threshold excitation energy for PPC in Al$_x$Ga$_{1-x}$N/AlN/GaN heterostructures with $x \approx 0.25$.

### 2. PPC: Annealing experiment

The thermal annealing dependence of the PPC effect was studied in the same cryostat, where the sample temperature was controlled with a controllable heater. Samples that were placed in a nonequilibrium state by optical illumination were annealed for 20 min at temperatures ranging from 20 to 280 K. After annealing, the temperature was ramped down to the initial temperature of 4.5 K, at which the final resistivity was recorded. The sample was then illuminated to set the sample in the same nonequilibrium state with same resistivity and carrier density before the next annealing step. The applied temperature profile for $T = 204.1$ K and the resulting temporal variation of sample resistivity for sample I are shown in Figs. 7(a) and 7(b), respectively. The initial reference resistivity for sample I before annealing was chosen as $\rho_{\text{xx}} = 57.2 \ \Omega$ which corresponds to $n_i = 6.2 \times 10^{12}$ cm$^{-2}$. After 20 min annealing, the final sample resistance was recorded as $60.5 \ \Omega$ ($n_i = 5.9 \times 10^{12}$ cm$^{-2}$). The change in carrier density is found to be larger for higher temperature annealing.

We have also performed similar annealing experiments on sample II for which we started from $\rho_{\text{xx}} = 49.5 \ \Omega$ ($n_i = 5.9 \times 10^{12}$ cm$^{-2}$). After each annealing step, the sample resistivity was decreased to this value with illumination at 4.5 K. Figure 8(a) illustrates how the carrier density changed with annealing temperature for sample II. The sample did not recover completely even with annealing near room temperature, at 280 K. Either the annealing time or annealing temperature should be increased for complete recovery, i.e., to reach $n_i \approx 1.6 \times 10^{12}$ cm$^{-2}$. However, when compared with sample I, one can conclude that PPC in sample II is much more sensitive to annealing. Figure 8(b) shows the amount of carrier density reduction recorded as a function of annealing temperature. The change in carrier density for the maximum annealing temperature of 280 K is $0.9 \times 10^{12}$ and $3.2 \times 10^{12}$ cm$^{-2}$ for samples I and II, respectively.

Despite the differences in the amount of recovery we get at given annealing temperature, for both samples annealing happens for a broad range of temperatures. Thus, we could extract a single energy barrier for thermal electron capture from our data. It is likely that a range of defects with different energy barriers participate in the PPC effect.

At this point we do not have a definitive explanation for the microscopic mechanism responsible for the different PPC responses measured for Al$_{0.25}$Ga$_{0.75}$N/AlN/GaN and Al$_{0.15}$Ga$_{0.85}$N/AlN/GaN samples under the influence of illumination and annealing. However, we can merely suggest the following interpretation. Based on the previous reports on PPC effect in Al$_{x}$Ga$_{1-x}$N/AlN/GaN, the...
origin of the PPC observed in these Al$_{0.25}$Ga$_{0.75}$N/AlN/GaN heterostructures may also be attributed to the excitation of deep level donors in the Al$_{0.25}$Ga$_{0.75}$N/AlN barrier layer. These deep levels can be compared with the DX centers in Al$_{0.25}$Ga$_{0.75}$N layers. Since the AlN interfacial layer is very thin, it is suggested that deep impurities in the 25 nm Al$_{0.25}$Ga$_{0.75}$N layer should be responsible for the PPC response. The difference in the intensity of PPC response for different Al concentration supports this proposition. Furthermore, we have observed that the sample with lower Al concentration, sample II, displayed a weaker PPC under illumination and a faster recovery under annealing when compared with sample I. This result suggests that the energy scales associated with the defect configuration coordinate diagrams should be different for these samples. For sample II, the stronger annealing response suggests that the thermal barrier to electron capture $E_c$ is smaller. Since the threshold energy values are similar, the defect configuration coordinates in Al$_{0.15}$Ga$_{0.85}$N and Al$_{0.25}$Ga$_{0.75}$N defects should be very close. Additional experiments are needed to clarify the detailed PPC mechanism and to model the exact defect configuration coordinates in the corresponding Al$_{0.25}$Ga$_{0.75}$N layers.

**IV. SUMMARY**

We have studied the spectral illumination and thermal annealing dependence of the persistent photoconductivity (PPC) effect in MOVPE-grown Al$_{x}$Ga$_{1-x}$N/AlN/GaN heterostructures. The PPC effect was used effectively to vary the carrier density and mobility in the 2DEG channel. SdH and Hall-effect measurements were performed to study the carrier density dependence of 2DEG mobility. The mobility and Hall-effect measurements were performed to study the carrier density and mobility in the 2DEG channel. SdH experiments are needed to clarify the detailed PPC mechanism and to model the exact defect configuration coordinates in the corresponding Al$_{0.25}$Ga$_{0.75}$N layers.

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